

Abstracts

Characteristics of deep-submicrometer MOSFET and its empirical nonlinear RF model

Yi-Jen Chan, Chia-Hung Huang, Chung-Chian Weng and Boon-Khim Liew. "Characteristics of deep-submicrometer MOSFET and its empirical nonlinear RF model." 1998 Transactions on Microwave Theory and Techniques 46.5 (May 1998, Part II [T-MTT] (Special Issue on Microwave Circuits on Silicon Substrates)): 611-615.

Si MOSFET's with submicrometer gate length were fabricated and characterized by RF evaluation. Devices with a $0.25 \mu\text{m}$ gate length demonstrated a g_{m} of 258 mS/mm , an f_T of 28 GHz , and a minimum noise figure of 1.8 dB at 900 MHz . A nonlinear device model was constructed based on the measured results. Empirical equations are used to represent the nonlinear elements such as g_{m} , C_{gs} , C_{gd} , C_{ds} , and R_{out} . These nonlinear elements, together with device parasitics, provide designers with a comprehensive model for using these devices for RF circuits.

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